Flying and Crawling Modes during Surface-Bound Single Wall Carbon Nanotube Growth

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Growth modes of single wall carbon nanotubes are investigated during chemical vapor deposition within an environmental transmission electron microscope and in furnace reactors at different gas pressure and flow conditions. The nanotube pivoting observed by in situ microscopy can be explained by dynamic catalyst crystallite reshaping for base growth. Microfabricated substrate barriers and gaps allow for the distinction between “crawling” and “flying” nanotubes, referring to either a continuous intimate contact with the substrate dominated by van der Waals forces or a mere substrate anchoring of nanotubes held afloat during growth. Crawling nanotubes grow unobstructed and straight to millimeter lengths and are susceptible to external forces. Crawling nanotubes are strongly affected by substrate topography. We relate this to tip and base growth regimes and discuss how the growth modes can be controlled.

Introduction

Bottom-up device integration of nanostructures such as single wall carbon nanotubes (SWNTs) requires their position, directional alignment, and structure to be controlled. These requirements can be addressed to various extents in a scalable fashion by catalytic, surface-bound chemical vapor deposition (CVD). Patterning of the catalyst by standard lithography determines the position of the SWNT nucleation sites.1 The dimensions of the catalyst nanoparticles and their dynamic interaction with support layers and feeding gases influence the nanotube morphology.2–7 Directional control has been demonstrated through gas flow alignment,8,9 applied electric fields,10 or support interactions, e.g., SWNT growth along stepped surfaces.11 Straight, suspended SWNTs have been grown between pillars or microstructured substrates.12–14

It is important to note, however, that the alignment mechanism depends on the growth mode of the SWNTs and their nucleation density. External electrostatic fields influence the alignment of the SWNTs only when overcoming their van der Waals (vdW) attraction to the substrate, i.e., when the nanotubes partially fly during growth.13 Alignment along step edges and crystal orientations, on the other hand, appears possible only when the SWNTs remain in intimate contact with the substrate.16 In the latter example, a base growth mode would additionally lead to shorter nanotubes than tip growth, since for base growth the bodies of SWNTs are required to slide over the support for which the interaction force increases with nanotube length. Finally, all horizontal alignment is suppressed if the SWNT nucleation density is so high as to allow growth only perpendicular to the substrate as a result of crowding.17

In this paper, we investigate the intimacy of the SWNT–substrate contact during catalytic CVD in order to establish how the growth environment influences the microscopic force balance. We use substrates with micro-fabricated barriers and gaps and combine environmental transmission electron microscopy (ETEM) of SWNT growth with post-growth analysis of SWNT alignment from various CVD reactors and operating conditions. Previously, ETEM investigations uncovered the nucleation stages of carbon nanofibres2,7 and SWNTs.7 Here the in situ growth reveals the motion of growing SWNTs. Our analysis provides evidence for two distinct growth modes: “flying”, where anchored SWNTs are generally afloat, and “crawling”, where the SWNT body is in continuous intimate contact with the substrate during growth. We relate this distinction to the catalytic base and tip growth regimes, allowing us to explain the growth of millimeter-long, straight SWNTs and the influence of external fields used in prior literature.

Experimental Methods

In situ TEM growth was carried out in a modified Tecnai F20, equipped with a differential pumping scheme (ETEM), operated at 200 kV.18 The microscope permits pressures of up to 10 mbar and video sequences can be recorded at 15 frames s−1. Ni catalyst films (99.9% purity) were thermally evaporated (base pressure 10−6 mbar) onto 2000 mesh Cu TEM grids (Agar Scientific) coated with SiO2 nanopowder (Degussa Aerosil Ox50) and a 30 nm sputtered SiO2 layer. Ni islands formed upon raising the temperature in vacuum, and growth was initiated in C2H2 at 8 × 10−3 mbar pressure and 600 °C.
Three substrate types were used for the other growth experiments: perforated SiO₂ membranes (SPI supplies), SiO₂ capped chips fabricated by surface micromachining of releasable polycrystalline silicon (poly-Si), and SiO₂ capped silicon-on-insulator (SOI) with etched-well structures. The wells in the SOI surface were formed by an anisotropic dry etch through a removable polymer mask to a depth of 60 nm, followed by a wet etch in HF to a total depth of 80 nm, and finally performing a thermal oxidation process to cap the exposed Si surfaces with ~10 nm of SiO₂. Consequently the sidewalls of these wells have a steep undercut profile, with an overhang of ~20 nm. Fe and Co catalyst films were thermally evaporated and patterned by standard photolithography.

Gas flow alignment was investigated in a 2 in. diameter atmospheric pressure quartz tube furnace. Growth with 0.1 nm Fe catalysts was carried out by heating the samples in an Ar atmosphere up to 900 °C, followed by a 10 min pretreatment in 200 sccm H₂ and growth in a 100/500 sccm H₂/CH₄ flow for 15 min. Growth with 0.3 nm Co catalysts was carried out by heating the samples in air up to 850 °C, followed by a 5 min purge in a 4000 sccm Ar flow. After the purge, the hydrocarbon source was introduced by bubbling a 100/1000 sccm H₂/Ar flow through a 5:100 H₂O to ethanol (by volume) solution held at room temperature for 30 min. In all cases, the growth was terminated by purging the furnace atmosphere with a 4000 sccm Ar flow before cooling to room temperature in Ar.

Growth in a static atmosphere was carried out in a low-pressure quartz tube furnace (LPCVD) with a base pressure of 10⁻⁵ mbar. Bimetallic catalyst films (1 nm Ni over 8 nm Al) were sputtered onto micromachined poly-Si or etched SOI substrates. The chips were transferred in air and subjected to H₂ pretreatment at 200 mbar and 850 °C for 10 min followed by the growth of SWNTs under CH₄ and H₂ (3:1) at 200 mbar for 15 min. Heating and cooling were performed under vacuum, and the chamber was opened only after cooling to below 250 °C.

SEM characterization was carried out in a LEO 1530VP or a Zeiss Ultra 55 FEG-SEMs, ex-situ TEM in a JEOL JEM 4000EX at 400 kV.

Results and Discussion

Figure 1 shows an ETEM image sequence of a SWNT growing from a Ni catalyst particle supported by amorphous silica nanopowder (see video 1 in the Supporting Information). Previous ETEM experiments in identical conditions showed that SWNTs nucleate by lift-off of a carbon cap, thereby following a base growth mechanism. Cap stabilization and nanotube growth involve the dynamic reshaping of the catalyst nanocrystal itself. Figure 1 shows that the body of the nanotube appears to bend and pivot while growing. When the nanotube touches the neighboring support, growth appears to stop. On the other hand, video 2 in the Supporting Information shows a case where growth continues after the nanotube’s attachment on a nearby support, followed by a straightening of its body across the gap. The origin of the pivoting motion will now be discussed in detail. Electron irradiation effects as systematic cause can be ruled out since ex situ grown SWNTs are routinely observed bridging nearest-neighboring features. The incorporation of defects can induce changes in the growth direction at the catalyst/nanotube interface. However, this effect can be excluded for the straight SWNTs observed here and in general whenever high quality SWNTs are grown. Gas flow alignment has been previously observed under atmospheric pressure growth conditions. For CVD in the ETEM, motion mediated by the gas flow cannot be excluded, though growth takes place at 8 × 10⁻³ mbar and the lack of SWNT alignment throughout the substrate indicates that gas mediated alignment is either negligible or the local gas flow direction over the substrate is nonuniform. Temperature-induced motion can be due to the thermal flexing vibrations of the cantilevered nanotube or the rigid pivoting around the nanotube’s base. The thermal flexing vibration cannot solely explain the motion in Figure 1, as the calculated average displacement of the cantilever’s tip at the growth temperature (~0.02 nm) is far below the observed value (~9 nm).

Consequently, catalyst particle reshaping appears as the most likely cause of the rigid pivoting at the nanotube’s base. Indeed, rapid changes in shape of the crystalline catalyst have been reported in the current growth environment and are consistent with the observed base growth mechanism.

The ETEM data can be related to typical post-growth observations for CVD, such as the bridging across pillars or gaps. Bridging has been reported up to length scales of 100 nm, with its extent varying according to growth conditions. Figure 2a,b shows SWNTs grown in static conditions, i.e., no gas flow, in a LPCVD system at 200 mbar, bridging rounded and sharp microfabricated poly-Si tips. Statistical observations show that the number of bridging SWNTs rapidly decreases for increasing gap widths. In these conditions, virtually no SWNTs are found bridging gaps wider than 3 μm. This directly relates to Figure 1: the wider the gap, the less likely for the SWNT to find an anchoring point. The effect can be exploited to control the SWNT position and bridging density, since closer tips increase the likelihood of having SWNTs bridging the gap, whereas sharper tips reduce the likelihood of having multiple SWNTs bridging a particular gap (Figure 2a,b). Longer distances can be spanned by imposing an electric field or a...
preferential gas flow,\textsuperscript{13} as shown in Figure 2c. Here the growth takes place in an atmospheric pressure furnace under a constant gas flow, which is found to induce the bridging of at least 30 \(\mu\)m gaps.

Another consequence of the observed motion is the bundling of nanotubes. While waving and pivoting (Figure 1), SWNTs are likely to come into contact with each other and form bundles due to vdW forces, as shown in Figure 2a,d. On the other hand, the vdW interaction with the substrate straightens them (Figures 2b,c). This accounts for the tautness commonly observed for suspended nanotubes (see also videos in Supporting Information).\textsuperscript{13,23} Figure 2d shows a typical TEM image recorded at the edge of a perforated SiO\textsubscript{x} membrane: some nanotubes are found spanning the gap straight, some bundle together forming Y-junctions near the support, and some closely follow the edge of the support before spanning the gap, presumably to decrease the slack of the suspended structure.\textsuperscript{23} The substrate–nanotube interactions can be found to be so strong as to cause SWNTs to buckle.\textsuperscript{23}

So far, we have provided evidence for interactions taking place when a nanotube is suspended. More commonly, SWNTs are grown on planar substrates. We now analyze if nanotubes grow in actual close contact with the substrate or rather are partially afloat, as for the suspended case. The influence of etched surface barriers on SWNT alignment is investigated by patterning catalyst films as lines parallel to, but not overlapping the barriers (see Figure 3a,b). SWNT synthesis is carried out in constant gas flow at atmospheric pressure, with free (Figure 3a,d) and obstructed (Figure 3c) gas flows over the substrate surface and in a static atmosphere at reduced pressure (Figure 3b). On the same sample obtained in free gas flow conditions at atmospheric pressure, we find flow-aligned straight SWNTs seemingly unaffected by the undercut barriers (as in Figure 3a), and SWNTs that do not pass over these barriers and remain entirely within the region where the catalyst was deposited (as in Figure 3b). Free gas flow over the substrate surface promotes the overcoming of barriers and alignment (Figure 3a,d) similarly to what observed in Figure 2c. Flow aligned SWNTs can be extremely long and straight (Figure 3d) with lengths of \(\sim\)1 mm routinely achieved for 15 min syntheses. This alignment is found to be insensitive to the effects of gravity, as one would expect from the negligible mass of the nanotubes. Flow alignment is not found at reduced pressures (Figure 3b) and can be suppressed in a standard atmospheric pressure furnace when the constant gas flow over the substrate surface is obstructed (Figure 3c). In the latter case, to suppress the flow alignment, the sample is placed catalyst-down over a flat crystalline silicon support coated by thermal amorphous silicon dioxide. This reduces the effect of the gas flow while retaining gas diffusion pathways within the microfissures existing between the surfaces in order to feed the growth. Under such conditions, SWNTs are typically not only constrained by the barriers but are shorter and not straight (Figure 3b,c).

Following these observations, we propose a distinction of growth modes not only between tip and base growth but also between crawling and flying (Figure 4). Crawling SWNTs are tip-grown and fully surface-bound, mainly subject to vdW forces and substrate-induced alignment forces (Figure 3b,c). Flying SWNTs are base- or tip-grown and partially surface-bound (Figure 3a,d). The forces acting upon them can be due to vdW interactions, thermal fluctuations, buoyant lift, gas flow, and externally applied electric fields. As shown in Figures 1 and 2 and the Supporting Information videos, flying SWNTSs easily anchor themselves to a nearby surface feature.
Crawling nanotubes tend to be nonstraight, short, and potentially more defective on amorphous or rough surfaces. This follows from the likelihood of the growing nanotube end to encounter an obstacle that can either change the direction of growth or stop growth entirely. A tip growth mechanism dominates for crawling tubes, since for base growth an increase in SWNT length results in increasingly strong vdW interactions with the substrate. Crawling SWNTs are not able to overcome large/undercut barriers (Figure 3b), as this would require an unlikely combination of sharp kinks in the body of the nanotube. Atomically flat substrates can improve the alignment of crawling nanotubes and have been shown to be effective for the growth of long SWNTs. Alignment has been shown along atomic-height step edges or along the substrate’s crystal orientation. Yu et al. postulate a raised-head mechanism similar to the crawling growth mode, but with a slightly raised SWNT tip, held separated from the surface due to electrostatic repulsion. Though we do not exclude this possibility, we still categorize this growth as crawling mode, given the close intimacy between SWNT and substrate, which prevents gas flow alignment.

Flying nanotubes are generally found to be longer and, whenever the appropriate conditions are present, straight and aligned. Being afloat limits substrate interactions and hence decreases the likelihood of pinning to an obstacle and of premature catalyst poisoning. This is supported by experiments of Huang et al., where nanotubes in slow heating conditions are short and not flow aligned (crawlers), but whenever a vertical electric field is applied to keep SWNTs afloat, the SWNTs are longer and flow aligned. A flying SWNT growth mode is compatible with both tip-growth and base-growth. The straightness of flying SWNTs varies with alignment method and experimental conditions. Catalyst patterning over raised structures or a vertical electric field were shown to increase the alignment yield. Gas flow aligned nanotubes are generally found to be straight over length scales varying from several tens of micrometers (Figure 3d) to centimeters but may include loops or be U-shaped. The degree of straightness reflects the dynamic conditions in the gaseous CVD environment: the more laminar the gas flow, the better the alignment. A highly laminar flow was reported to result in centimeter-long, straight SWNTs. This length scale is believed to originate from buoyant forces preventing the growing nanotube from completely adhering to the substrate. The presence of loops can be induced by the rapid attachment of the flying SWNTs to the substrate, whereas U-shaped nanotubes can originate from the pinning of the SWNT’s tip while growth at its base continues (see also video 2 in the Supporting Information).

Supporting Information Available: ETEM videos (Quicktime, H.263) of Ni catalyzed SWNTs grown at 600 °C in C2H2 at 8 × 10⁻³ mbar. Video 1 shows a SWNT pivoting and bridging a nearby support feature. Video 2 shows a SWNT growing after attachment. This material is available free of charge via the Internet at http://pubs.acs.org.
References and Notes